## WHAT IS CLAIMED IS:

- 1. A process for preparing an end-functionalized conjugated oligomer of a polyarylene comprising the steps of:
  - a) effecting a reaction between a compound comprising a phenol, thiol or amine functional moiety which is substituted with an aryl halide or aryl boronic acid or ester, and a compound selected from a bis-boronic acid or ester or a bis-haloarene to form an oligiomer;
  - b) isolation and purification of the oligomer.
- 2. The process of claim 1 wherein the phenol, thiol or amine functional moiety is reacted with a compound having the formula:

wherein each R is selected from the same or different moiety selected from straight or branched alkyl, substitute alkyl, aryl or substituted aryl radicals.

3. The process of claim 1 wherein the phenol, thiol or amine functional moiety is a compound of the formula:

wherein Ar is an aromatic moiety, A is O, S or N and n is 1 or 2.

4. The process of claim 3 wherein the Ar aromatic moiety is selected from phenyl, substituted phenyl, naphthyl, substituted naphthyl, anthryl, substituted anthryl biphenylyl, and substituted biphenylyl.

5. The process of claim 2 wherein the resulting oligomer has the formula:

$$H_nA$$

wherein Ar is an aromatic moiety, A is O, S or N, n = 1 or 2 and each R is selected from the same or different moiety selected from straight or branched alkyl, substituted, straight or branched alkyl, aryl or substituted aryl.

- 6. The process of claim 5 wherein the Ar aromatic moiety is selected from phenyl, substituted phenyl, naphthyl, substituted naphthyl, anthryl, substituted anthryl biphenylyl, and substituted biphenylyl.
- 7. A process for forming a polymer comprising a series of end functionalized conjugated oligomers of a polyarylene comprising the steps of:
  - a) effecting a reaction between a compound comprising a phenol, thiol or amine functional moiety which is substituted with an aryl halide or aryl boronic acid or ester, and a compound selected from a bis-boronic acid or ester or a bis-haloarene to form an oligiomer having an amine thio or amine functional moiety formed thereon;

- b) isolation and purification of the oligomer having an amine thio or amine functional moiety formed thereon; and
- c) reacting the phenol, thiol or amine functional moiety present on the oligiomer of step b) with a diffunctional monomer to form a polymer.
- 8. The process of claim 7 wherein the phenol, thiol or amine functional moiety on the compound of step a) is reacted with a compound having the formula:

$$(HO)_2B$$
 $R$ 
 $B(OH)_2$ 

wherein each R is selected from the same or different moiety selected from straight or branched alkyl, substitute alkyl, aryl or substituted aryl radicals.

9. The process of claim 7 wherein the compound comprising a phenol, thiol or amine functional moiety in step a) is a compound of the formula:

$$H_nA$$
  $Br$ 

wherein Ar is an aromatic moiety, A is O, S or N and n is 1 or 2.

10. The process of claim 9 wherein the Ar aromatic moiety is selected from phenyl, substituted phenyl, naphthyl, substituted naphthyl, anthryl, substituted anthryl biphenylyl, and substituted biphenylyl.

11. The process of claim 9 wherein the resulting oligomer has the formula:

wherein Ar is an aromatic moiety, A is O, S or N, n = 1 or 2 and each R is selected from the same or different moiety selected from straight or branched alkyl, substituted, straight or branched alkyl, aryl or substituted aryl.

- 12. The process of claim 11 wherein the Ar aromatic moiety is selected from phenyl, substituted phenyl, naphthyl, substituted naphthyl, anthryl, substituted anthryl biphenylyl, and substituted biphenylyl.
  - 13. The process of claim 12 wherein Ar is selected from 4-t-butylphenyl.
- 14. The process of claim 7 wherein the difunctional monomer is a compound selected from BPA-bis-chloroformate, terephthalic acid, terephthalic diacid chloride, dichlorophenylsulfone, pyromellitic dianhydride, adipolychloride, diphenyldichlorosilane, dimethyldichlorosilane, phosgene, 1,1,3,3-tetramethyldisiloxane and mixtures thereof.
- 15. The process of claim 5 wherein the oligomer of claim 5 is further polymerized with a difunctional monomer having the formula MX<sub>2</sub> to form a polymeric compound having the formula:

where  $MX_2$  is a diffunctional monomer which is capable of reacting with the AHn group to form a polymer.

- 16. The process of claim 15 wherein the MX<sub>2</sub> difunctional monomer is a compound selected from BPA-bis-chloroformate, terephthalic acid, terephthalic diacid chloride, dichlorophenylsulfone, pyromellitic dianhydride, adipolychloride, diphenyldichlorosilane, dimethyldichlorosilane, phosgene, 1,1,3,3-tetramethyldisiloxane, and mixtures thereof.
  - 17. An end-functionalized oligomer produced by the process of claim 1.
  - 18. A polymer prepared by the process of claim 7.
- 19. A light emitting device comprising an active layer, wherein said active layer is formed from a polymer produced in accordance with the process of claim 7.
- 20. A photovoltaic device comprising an active layer, wherein said active layer is formed from a polymer produced in accordance with the process of claim 7.
  - 21. A polymer composition comprising a polymer of the general formula:

$$[(D-G_n-D)-M]_m$$

wherein D is an "A-functional" segment of the general formula:

wherein Ar is an aromatic unit, A is selected from the group consisting of O, N, and S, and a is an integer between about 1 and 3; G is an oligophenylene; n is an integer between about 1 and 25, M is a linking group, and m is an integer between about 1 and 1000.

- 22. The composition of claim 21 wherein said aromatic unit is selected from the group consisting of phenyl, substituted phenyl, naphthyl, anthryl, biphenyl, substituted variants thereof, and mixtures thereof.
- 23. The composition of claim 21 wherein said M is formed by reacting at least one  $MX_2$  with the (D-G<sub>n</sub>-D) segments.
- 24. The composition of claim 23 wherein said MX<sub>2</sub> is selected from the group consisting of BPA-bis-chloroformate, terephthalic acid and its diacid chloride, dichlorophenylsulfone, pyromellitic dianhydride, adipochloride, diphenyldichlorosilane, dimethyldichlorosilane, 1,1,3,3-tetramethyldisiloxane, phosgene, and mixtures thereof.